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Fe ions have been doped in gallium nitride (GaN) as deep acceptors for compensating n-type carriers to achieve a semi-insulating GaN, which is a key material in various electric devices such as a high-electron-mobility transistor (HEMT). The device performances, however, deteriorate with increasing temperature. Deeply trapped carriers in the bulk GaN can be thermally activated, causing the hopping conduction, which creates the additional electron pass and affects the carrier mobility. It is thus important to understand electron transport behavior at elevated temperatures in the semi-insulating GaN.

Equally important issue is the piezoelectricity of GaN. Wurtzite GaN shows five independent elastic constants $C_{ij}$ and three independent piezoelectric coefficients $e_{ij}$ ($e_{33}, e_{31}$, and $e_{15}$). A complete set of $C_{ij}$ was determined with resonant ultrasound spectroscopy (RUS) for bulk GaN specimens, where $e_{ij}$ were deduced as well, but they were significantly underestimated because of high carrier densities of the specimens. A few theoretical and experimental studies gave $e_{33}$ and $e_{31}$ values, but they significantly differ from each other. (The standard deviation of reported values of $e_{33}$ exceeds 20% of their averaged value, for example.) Furthermore, few theoretical reports and no direct measurement appear for $e_{15}$, the piezoelectric coefficient related to the shear stress. Thus, the piezoelectricity of GaN still remains unclear despite its crucial contribution to the two-dimensional electron gas in HEMT devices. Simultaneous determination of $C_{ij}$ and $e_{ij}$ has been proven to be possible with the RUS method. However, it required extraordinarily precise measurements on resonant frequencies, specimen dimensions, and specimen mass density because of small contributions of $e_{ij}$ to frequencies, and is therefore inapplicable to GaN because contributions of $e_{ij}$ are considerably smaller due to high stiffness.

In this study, we propose a methodology for evaluating the carrier dynamics and piezoelectricity in Fe-doped GaN with the antenna-transmission resonant ultrasound spectroscopy and determine the activation energy of the hopping conduction and the piezoelectric coefficient $e_{15}$. The free-carrier flow is restricted in an insulated semiconductor, and the conduction principally occurs by hopping of trapped carriers by acceptors between the sites. The hopping conduction is a thermally activated phenomenon; the phonon-assisted carrier movement is efficiently enhanced when the polarization-switching rate caused by ultrasonic vibration is matched with the jump rate of a carrier from site to site. Thus, focusing a resonant mode, internal friction shows a maximum with increasing temperature because a part of the acoustic energy is spent on the carrier movement, and the frequency decrement (modulus defect) occurs at the matching temperature. The resonance-frequency change $\Delta f$ and corresponding attenuation coefficient $\alpha$ take the Debye-type relaxation forms

$$\frac{\Delta f}{f} = \frac{e^2}{2C_\epsilon} \frac{(\omega \tau)^2}{1 + (\omega \tau)^2},$$

$$\alpha = \frac{e^2}{2C_\epsilon} \frac{\omega \tau}{1 + (\omega \tau)^2}. \tag{2}$$

Here, $\omega$ is the angular frequency, and $e, C$, and $\epsilon$ denote the effective piezoelectric, elastic, and dielectric constants dominating the resonant mode. $\tau$ denotes the relaxation time for the carrier hopping expressed by $\tau = \rho \tau$ with the resistivity $\rho$. The attenuation coefficient thus shows a peak at $\omega \tau = 1$, across which the modulus defect appears. Because the resistivity is inversely proportional to the Boltzmann factor ($\rho \propto \exp(E/kT)$), an Arrhenius plot for the peak attenuation yields the activation energy $E$. The resonance-frequency shift across the attenuation peak reflects the disappearance of the apparent piezoelectricity due to the hopping conduction, and it is possible to determine the piezoelectric coefficient by measuring the frequency shift. This approach determines the piezoelectric coefficient much more accurately than the conventional methods because the frequency shift can be accurately measured by monitoring the relative frequency change. (Note that the previous
method requires absolute measurements for frequencies with extraordinary precision.)

The material we used was grown with a hydride-vapour-phase-epitaxy (HVPE) method. Because the HVPE method introduces many donors mainly from silicon and oxygen, Fe ions were introduced to compensate them. The resistivity at room temperature and Fe concentration are $2 \times 10^{18} \Omega \text{cm}$ and $8 \times 10^{18} \text{cm}^{-3}$, respectively. The mass density determined by the Archimedes method is 6.080 g/cm$^3$. The GaN wafer was machined to obtain a rectangular-parallelepiped specimen with $3.493 \times 2.990 \times 0.410$ mm$^3$. (The $c$ axis is along the thickness direction.)

The antenna-transmission technique was used for causing free vibrations of the thin GaN specimen contactlessly through the piezoelectric coupling with dynamic electric fields. Two line-antenna configurations were developed as illustrated in Figs. 1(a) and 1(b) for multimode and single mode excitations, respectively. The former causes the dynamic electric field along inclined directions to the surface, exciting various vibrational modes as shown in Fig. 1(c), while the latter principally causes the electric fields parallel to the surface, which is coupled into the shear deformation through $\varepsilon_{15}$, giving rise to the shear vibration strongly as shown in Fig. 1(d). The specimen and antenna were set inside a tube heater located in a vacuum chamber, where the pressure during the experiments was kept under $\sim 1 \times 10^{-2}$ Pa. Details of the high-temperature non-contacting RUS system appear elsewhere. The attenuation coefficients were measured from the ring-down signals after excitation with tone bursts. The acoustically contactless measurement is the key for the accurate attenuation measurement, because any contacts to the specimen cause energy leakage, leading to significantly larger apparent attenuation.

Figure 2 shows temperature behavior of the attenuation coefficient for various resonance modes. The attenuation-peak temperature rises as the frequency increases, and the Arrhenius plot yields the activation energy of $0.23 \pm 0.05$ eV. Previous studies used optical spectroscopy methods for studying excited states of Fe ions in GaN, where the formation of an Fe$^{2+}$-hole complex was suggested and their binding energy was estimated. However, various energy bands were superimposed in their spectra, and it was fairly difficult to identify the energy states with the phonon-assisted charge transfer process from such broad spectra. For example, Heitz et al. estimated the binding energy for the complex to be 0.28 eV, whereas Malguth et al. denied this value and presented a much smaller value of 0.05 eV. Thus, the lower energy bands of the charge transfer processes coupled with phonons have not been clearly observed. In contrast, our acoustic-resonance method allows the direct excitation of the phonon-assisted carrier flow and then unambiguous determination of the activation energy. Our value, 0.23 eV, is closer to that estimated by Heitz et al.

Also challenging subject is determination of the piezoelectric coefficient, especially $\varepsilon_{15}$. Cooling from high enough temperature increases the relaxation time for hopping of carriers and they eventually fail to follow the polarization change caused by acoustic vibration at temperatures below enough the attenuation-peak temperature. This causes an increase in the resonant frequency, corresponding to the piezoelectric stiffening. Thus, the frequency shift reflects the piezoelectric coefficient, which can be determined by measuring the frequency shift. Although many resonant peaks are observed with the antenna configuration in Fig. 1(a), most of them disappear at elevated temperatures beyond the attenuation peak due to disappearing of piezoelectricity, and we failed to measure the frequency changes accurately. However, we find that the nearly pure shear-resonance mode is observable even at temperatures beyond the attenuation peak as shown in Fig. 3: The antenna configuration in Fig. 1(b) causes the in-plane dynamic electric field, which selectively excites and detects the shear vibrations through the coupling with $\varepsilon_{15}$, making the single resonance peak.

![Figure 1](image1.png)  
**FIG. 1.** (a) Antenna configuration for multimode excitation and (b) that for shear mode excitation. (c) Resonant spectrum measured by the multimode antennas and (d) that by the shear-mode antennas. The inset enlarges the measurement near the single peak.

![Figure 2](image2.png)  
**FIG. 2.** Temperature dependence of the attenuation coefficient with various frequencies. The inset shows the Arrhenius plot, yielding the activation energy.
observable at 14.8 MHz (Fig. 1(d)), which is nearly identical to the third through-thickness shear-wave resonance. (Using the reported shear modulus $C_{44} = 98.0$ GPa,\textsuperscript{13} the third through-thickness shear-wave resonance frequency is calculated to be 14.7 MHz.) The frequency shift and corresponding attenuation peak are clearly observed for this mode as shown in Fig. 3, where theoretical calculations based on Eqs. (1) and (2) are shown with solid lines. The frequency and attenuation behaviors were identical between the heating and cooling processes, indicating the thermally activated relaxation phenomenon. Note that, however, the piezoelectric stiffening does not occur for the pure shear plane wave propagating along the $c$-axis, and the shear free vibration at 14.8 MHz is not the same as the plane-wave resonance mode. Therefore, exact mode identification and precise calculation of the $e_{15}$ contribution to this mode are necessary.

We computed free-vibration resonance frequencies using the Ritz method with basis functions composed of the Legendre-polynomial products\textsuperscript{19,29} $P_l(x_1/L_1)P_m(x_2/L_2)P_n(x_3/L_3)$, where $P$ represents the normalized Legendre function, and $x_1$, $x_2$, and $x_3$ are the Cartesian coordinates along the rectangular-parallelepiped edges (along 3.493-mm, 2.990-mm, and 0.410-mm edges), respectively. $L_i$ denotes the edge length along the $x_i$ axis of the specimen. $l$, $m$, and $n$ denote the order numbers of the Legendre polynomial ($l + m + n \leq N$). For calculating the resonance frequencies at higher modes, we need to involve sufficiently higher-order Legendre polynomials. Figure 4 displays differences of computed resonance frequencies from those using Legendre polynomials up to $N = 70$, in which more than 7800 basis functions are involved in the computation for each vibration group. (There are eight vibrational groups in an oriented GaN rectangular parallelepiped, depending on the symmetry of deformation and electric potential.\textsuperscript{29}) The resonance frequencies converge to the true values with increasing the number of basis functions, and the difference from the true values will be smaller than 0.001% with $N = 70$ even for frequencies near 15 MHz. We thus involved about 7800 basis functions with $N = 70$ for calculating the piezoelectric coefficient.

Among the eight vibrational groups, $B_{2g}$ and $B_{3g}$ groups are candidates for the 14.8 MHz resonance mode, because they show the identical deformation symmetry to the through-thickness shear-wave resonance modes. We then identified the 14.8 MHz mode to be 273th overtone of the $B_{3g}$ vibrational group because of three reasons. First, its computed frequency (14.83 MHz) is close to the measurement at room temperature (14.81 MHz). Second, it is highly affected by the shear modulus $C_{44}$ (contribution of $C_{44}$ exceeds 80%), being similar to the through-thickness shear modes. Third, it shows similar displacement distribution to that of the third through-thickness shear resonance as shown in the inset in Fig. 5: The shear displacement along the $x_2$ axis shows nearly uniform distributions in $x_1$-$x_2$ planes, and it shows the odd symmetry along the thickness direction, which coincides with the oppositely excited tangential
electric fields on both surfaces. We calculated the contributions of the three piezoelectric coefficients to the B3g-273 mode and found that $\varepsilon_{15}$ was dominant compared with the other two coefficients: Contributions of $\varepsilon_{33}$ and $\varepsilon_{13}$ are smaller than that of $\varepsilon_{15}$ by factors of 0.1. Therefore, we independently calculated the sensitivity of $\varepsilon_{15}$ to the frequency as shown in Fig. 5: We calculated the frequency shift from the non-piezoelectric state ($e_{ij} = 0$) by varying $e_{15}$ and compared it with the measurement to determine $e_{15}$. In this calculation, we used $C_{ij}$ values from our previous measurements\(^{13}\) and reported dielectric constants $\varepsilon_{11}/\varepsilon_0 = 5.35^{30}$ and $\varepsilon_{33}/\varepsilon_0 = 5.80^{31}$ (We also involved reported piezoelectric constants $\varepsilon_{33}$ and $\varepsilon_{13}$,\(^{16}\) but they are not sensitive to the resultant $\varepsilon_{15}$ as mentioned above.) Our measurements provided the frequency shift of 0.104 ± 0.03%, yielding $e_{15} = -0.332 \pm 0.03 \text{ C/m}^2$. The absolute value is smaller than that of the reported theoretical value ($-0.38 \text{ C/m}^2$)\(^{16}\) by 14%.

In summary, we have acoustically measured the activation energy of carrier’s hopping conduction in Fe-doped GaN. The temperature dependence of the relaxation time was evaluated through the vibration-attenuation peak, and the Arrhenius plot yielded the activation energy to be 0.23 ± 0.05 eV. The piezoelectric coefficient $e_{15}$ related to the shear deformation was then determined by the frequency decrement for the quasi shear resonance mode caused by disappearance of piezoelectricity due to the hopping conduction. Because there is no measurement and only one theoretical report on $e_{15}$, our measurement value $e_{15} = -0.332 \pm 0.03 \text{ C/m}^2$ is crucially important.


\(^{17}\)Y. Duan, J. Li, S. Li, and J. Xia, J. Appl. Phys. 103, 023705 (2008).